

Notice of References Cited	Application/Control No. 10/673,214		Applicant(s)/Patent Under Reexamination SUZUKI ET AL.	
	Examiner Fernando L. Toledo		Art Unit 2823	Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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*	B	US-6,127,695 A	10-2000	Harris et al.	257/77
*	C	US-6,136,654 A	10-2000	Kraft et al.	438/287
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*	H	US-6,780,278 B2	08-2004	Hayashi et al.	156/345.47
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Wolf and Tauber, Silicon Processing for the VLSI Era Volume 1: Process Technology, p. 198, 1986, Lattice Press, Sunset Beach, CA.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.